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Nanotechnologies — Silica nanomaterials — **Specification of** Characteristics and measurement methods for silica with ordered nanopore array (SONA)

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Foreword

ISO (the International Organization for Standardization) is a worldwide federation of national standards bodies (ISO member bodies). The work of preparing International Standards is normally carried out through ISO technical committees. Each member body interested in a subject for which a technical committee has been established has the right to be represented on that committee. International organizations, governmental and non-governmental, in liaison with ISO, also take part in the work. ISO collaborates closely with the International Electrotechnical Commission (IEC) on all matters of electrotechnical standardization.

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https://standards.iteh.ai/catalog/standards/sist/9c547097-31ef-4e6f-96ce-da4befdcd8ea/iso-dts-22298 The committee responsible for This document iswas prepared by Technical Committee ISO/TC 229, Nanotechnologies.

Any feedback or questions on this document should be directed to the user's national standards body. A complete listing of these bodies can be found at www.iso.org/members.html.

Introduction

Silica with ordered nanopore array (SONA) is expected to act as novel catalysts and adsorbents because of the presence of their uniform nanopores. In addition to <u>themSONA</u>, recently developed synthetic strategies have created a huge number of compositional and morphological variations. Therefore, <u>itSONA</u> is expected to be applied in various fields such as electronics, optics, and materials. They <u>have stimulated</u> various applications such as electronic, photonic, and materials applications. Also, they<u>also</u> have potential uses as electrodes for fuel cells and hydrogen-storage materials, all of which are owing to the presence of periodic nanopore and the physical properties of inorganic frameworks.

SONA as described in the previous reports^[1_1_1_5] has an amorphous structure like silica-gel and exhibits a honeycomb (hexagonal), 3D (cubic) and wormhole (gyroid) pore structure (see Annex A) with ordered cylindrical channels from 2 nm to 50 nm in diameter. The pores are constructed with thin silica walls which are connected to form the regular pore arrangements. The delicate structures of silica walls and their connected structures are influenced by their preparation, aging and storage conditions. The global SONA market is anticipated to witness significant growth on account of a wide range of existing and potential applications of the product in electronics, biomedical, drug delivery, and optical fields. A market survey shows extensive use of SONA in the chemical industry as a catalyst support for synthesis of various chemicals^[6].

SONA have a variety of industrial applications as catalysts, adsorbents, molecular sieve, where their properties and use cases highly depend on their production processes that affect their nanopore arrangements. They do not have long-range SiO₂ ordering confirmed by powdered X-ray diffraction, showing XRD peaks in low angle region (see Annex A). Having the ability to characterize these materials helps developers adapt to new research frontiers such as bulky organometallic or inorganic complexes, biosensors from embedded enzymes on nanostructured silica- $[_{L}^{[7]}, -1^{[8]}]$, to application in energy-efficient desiccation. Standardization of SONA can unify different types of SONA test reports in industry. This allows users to compare or select most suitable and qualified SONA for their applications.

Technical Specification

<u>ISO/DTS 22298</u>

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<u>Nanotechnologies — Silica nanomaterials — Characteristics and</u> <u>measurement methods for silica with ordered nanopore array (SONA)</u>

1 Scope

<u>This document</u> specifies the characteristics of <u>silica</u>-samples <u>of silica</u> with ordered nanopore array <u>(SONA)</u> to be measured <u>in powder form</u> and <u>specifiesthe</u> industrially available measurement methods used to determine said characteristics. <u>It This document</u> provides a sound base for the research, development₇ and commercialization of SONA for various applications.

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Nanotechnologies – Silica nanomaterials - Specification of characteristics and measurement methods for silica with ordered nanopore array (SONA)

1—1 Scope

This document specifies characteristics to be measured and their measurement methods of silica with ordered nanopore array (SONA) in powder form.

-This document excludes silica-gel, fumed silica and chemically modified SONA.

NOTE <u>1</u>:—The pore size of SONA ranges usually from one <u>nanometernanometre</u> to several tens of <u>nanometersnanometres</u>.

2 **2**-Normative references

ISO/TS 80004-2 Nanotechnologies – Vocabulary – Part 2: Nano-objects

ISO/TS 80004-4 Nanotechnologies - Vocabulary - Part 4: Nanostructured materials

ISO/TS 80004-6 Nanotechnologies – Vocabulary – Part 6: Nano-object characterization

There are no normative references in this document.3

3 Terms and definitions iTeh Standards

For the purposes of this document, the following terms and definitions apply.

ISO and IEC maintain terminology databases for use in standardization at the following addresses:

— ISO Online browsing platform: available at https://www.iso.org/obp

— IEC Electropedia: available at https://www.electropedia.org/

https://standards.iteh.ai/catalog/standards/sist/9c547097-31ef-4e6f-96ce-da4befdcd8ea/iso-dts-22298 **3.1**

area equivalent diameter

diameter of a circle having the same area as the projected image of the particle

Note 1 to entry: It is also known as the Heywood diameter or as the equivalent circular diameter.

[SOURCE: ISO 13322-1:2014(en), 3.1.1]

3.2

Feret diameter

<u>x</u>_F

distance between two parallel tangents on opposite sides of the image of a particle

Note 1 to entry: Maximum diameter x_{Fmax} corresponding to the "length" of the particle and minimum diameter x_{Fmin} corresponding to the "breadth" of the particle.

[SOURCE: ISO 13322-2:2004, 3.1.6-1:2014, 3.1.6, modified — Note 1 to entry has been added.]

3.3

nanopore

cavity with at least one dimension in the *nanoscale* (3.4), which <u>maycan</u> contain a gas or liquid

Note 1 to entry: The shape and content of the cavity can vary. The concept of nanopore overlaps with micropore (<u>i.e.</u> pore with width of about 2 nm or less), mesopore (<u>i.e.</u> pore with width between approximately 2 nm and 50 nm), and macropore (<u>i.e.</u> pore with width greater than about 50 nm).

Note 2 to entry: When nanopores are appropriately interconnected, they <u>maycan</u> allow for transport through the material (<u>i.e.</u> permeability].

[SOURCE; ISO/TS 80004-4, 2.13]

1:2023, 3.4.3, modified — Notes 1 and 2 to entry have been added.]

<u>3.4</u>

nanoscale

size range from approximately 1 nm to 100 nm

Note 1 to entry: Properties that are not extrapolations from a larger size will typically, but not exclusively, be exhibited in this size range. For such properties, the size limits are considered approximate.

Note 2 to entry: The lower limit in this definition (approximately 1 nm) is introduced to avoid single and small groups of atoms from being designated as nano-objects or elements of nanostructures, which <u>mightcan</u> be implied by the absence of a lower limit.

[SOURCE: ISO/TS 80004-1:2010,2023, 3.1.1, modified — Notes 1 and 2.1] to entry have been added.]

3.5

ordered nanopore array

nanopores (3.3) formed and arranged in a pattern according to the specified rule

Note 1 to entry: The ordered nanopore array can be fully or partially regular depending on the *SONAsilica with ordered nanopore array* (3.7) sample.

Note 2 to entry: See Annex A for the types of pore array.

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3.6ps://standards.iteh.ai/catalog/standards/sist/9c547097-31ef-4e6f-96ce-da4befdcd8ea/iso-dts-22298 particle size

dimension that is representative of the size of an individual particle

Note to entry: The particle size is usually expressed as Feret diameter or area equivalent diameter

[diameter of sediment particles

[SOURCE: ISO 772:2011(en), 6.37 modified, note to entry added.]2022, 8.41]

3.7

pore size

pore width, i.e., diameter of cylindrical pore or distance between opposite walls of slit-

[SOURCE: <u>ISO15901ISO 15901</u>-2÷:2022, 3.17]

3.8

pore size distribution

fraction by numbers or by volume of each classified *pore size* (3.7) which exists in a material

Note 1 to entry; The pore size distribution is usually expressed by the full width at half maximum of the distribution main peak.

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[<u>SOURCE:</u> ISO 3252:20192023, 3.3.47, <u>modified — "percentage" has been</u> replaced with <u>"fraction}" in the definition and Note 1 to entry has been added.</u>]

3.9

silica with ordered nanopore array SONA

amorphous silica containing internal structures in the form of *ordered nanopore array* (3.5)

4 4-Abbreviated terms

AAS atomic absorption spectrometry

AFM atomic force microscopy

BET Brunauer-Emmett-Teller

BJH Barrett-Joyner-Halenda

DSC differential scanning calorimetry

EDX energy dispersive X-ray spectrometry

EPMA electron probe micro analyser

ICP inductively coupled plasma en Standards

IR infrared spectrometry

SEM scanning electron microscopy

Si-MAS-NMR silicon magic angle spinning-nuclear magnetic resonance

TEM transmission electron microscopy TS 22298

https://standards.iteh.ai/catalog/standards/sist/9c547097-31ef-4e6f-96ce-da4befdcd8ea/iso-dts-22298 TGA thermal gravimetric analysis

XRD X-ray diffraction

XRF X-ray fluorescence spectrometry

- XPS X-ray photoelectron spectrometry
- AAS atomic absorption spectrometry
- <u>AFM</u> atomic force microscopy
- BET Brunauer–Emmett–Teller
- BJH Barrett-Joyner-Halenda
- EDX energy dispersive X-ray spectrometry
- <u>EPMA</u> <u>electron probe micro analyser</u>
- ICP inductively coupled plasma
- <u>SEM</u> <u>scanning electron microscopy</u>
- TEM transmission electron microscopy